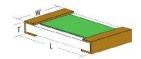
# **SURFACE MOUNT RESISTORS**

# Wrap Around (WATF)



Solderable gold with nickel barrier OR Nickel barrier pre-soldered

# Half-Wrap (HWTF)



Solderable gold with nickel barrier OR Nickel barrier pre-soldered Isolated pad is wire bondable

Mini-Systems, Inc. **Surface Mount Chip Resistors** are available in a wide range of case sizes, with each size offered in wrap around and half wrap termination styles. All solderable terminations have a nickel barrier for enhanced solder performance. This series is designed to be connected to associated circuitry through wire-bonding, conductive epoxy or soldering. Mini-Systems, Inc. time tested materials produce chip resistors with high stability, low noise and low TCR to provide the hybrid electronics industry resistor products with the highest standards available.

#### **GENERAL CHARACTERISTICS**

Resistance Range	$1\Omega$ to $6  ext{M}\Omega$
Resistance Tolerance	±0.01% to ±10%
Termination Material	(NU) Solderable Gold with Nickel Barrier, (NT) Nickel with Solder
Operating Temperature	-55°C to +150°C
Storage Temperature	-65°C to +150°C
Operating Frequency	DC to 500 MHz

## SUBSTRATE CHARACTERISTICS

	Available	Dielectric	Thermal	Current Noise		
SUBSTRATE MATERIAL	Thickness	Constant @ 1MHz	Conductivity W/m• K	$101\Omega$ to $250 k\Omega$	$\leq 100\Omega > 250 \mathrm{k}\Omega$	
99.6% Alumina	0.010" - 0.025"	9.9	28	-35dB	-30dB	
Beryllium Oxide	0.010" - 0.025"	6.7	300	-30dB	-20dB	
Aluminum Nitride	0.010" - 0.025"					

#### **RESISTOR CHARACTERISTICS**

RESISTOR FILM	Passivation	Standard TCR	TCR Optional To:	
Tantalum Nitride	Ta <sub>2</sub> O <sub>5</sub> (Self Passivating)	±150 ppm/°C	±10 ppm/°C	
NiChrome	SiO <sub>2</sub>	±25 ppm/°C	±5 ppm/°C	

#### PART NUMBER DESIGNATION

WATF	<u> </u>	– A	T —	100R0	F	NT3
STYLE	ТҮРЕ	SUBSTRATE	RESISTOR FILM	OHMIC VALUE	TOLERANCE	OPTION
WATF	SEE	A = Alumina	T = Tantalum Nitride	5-Digit Number:	$S = \pm 0.01\%$	$D = \pm 5ppm/^{\circ}C$
HWTF	TABLE	B = BeO	N = NiChrome	1st 4 digits are significant	$Q = \pm 0.05\%$	$C = \pm 10 \text{ppm/}^{\circ} C$
		N = AlN		with "R" as decimal	$B = \pm 0.1\%$	$B = \pm 25 ppm/^{\circ}C$
				point when required.	$D = \pm 0.5\%$	$A = \pm 50 \text{ppm/}^{\circ}\text{C}$
				5th digit represents	$F = \pm 1\%$	$F = \pm 100 \text{ppm/}^{\circ}\text{C}$
				number of zeros.	$G = \pm 2\%$	NU = Soldereable Au w/ Ni barrier
					$J = \pm 5\%$	NT3 = Nickel w/ SAC305 Solder
					$K = \pm 10\%$	NT = Nickel w/ Sn62 Solder
						TR = Tape and Reel

EXAMPLE: WATF-5-AT-100R0F - NT3

WATF-5 Series, Alumina, Tantalum Nitride,  $100\Omega$ ,  $\pm 1\%$  Tol., Nickel w/ SAC305 Solder, RoHS Compliant



## THIN FILM DIVISION

ISO 9001 CERTIFIED 20 DAVID ROAD NORTH ATTLEBORO, MA 02760

EMAIL: msithin@Mini-SystemsInc.com
WEB: www.Mini-SystemsInc.com
PHONE: 508-695-0203 FAX:508-695-6076



# SURFACE MOUNT RESISTORS

		DIMENSIONS			RESISTANCE RANGE		POWER RATING 1		
CASE SIZE	ТҮРЕ	L (±0.003") [±0.076mm]	W (±0.003") [±0.076mm]	T <sup>2</sup> (±0.003") [±0.076mm]	Low Values NiCr or TaN (Std. TCR Only) (Tol.≥0.5%)	Standard Values NiCr or [TaN]	Alumina	AlN	BeO
0201	21	0.020" [0.508]	0,010" [0.254]	0 <b>.</b> 006" [0.152]	1Ω < 3Ω	3Ω <b>-</b> 55kΩ [80kΩ]	50mW	200mW	400mW
0202	7	0.020" [0.508]	0.020" [0.508]	0.010" [0.254]	$1\Omega < 3\Omega$	3Ω - 130kΩ [190kΩ]	125mW	500mW	1W
0302	32								
0402	1	0.040" [1.016]	0.020" [0.508]	0.010" [0.254]	1Ω < 3Ω	3Ω - 200kΩ [300kΩ]	125mW	500mW	1W
0404	2								
0502	8	0.055" [1.397]	0.025" [0.635]	0.010" [0.254]	1Ω < 3Ω	3Ω - 250kΩ [400kΩ]	250mW	1W	2W
0505	4								
0603	63	0.060" [1.524]	0.030" [0.762]	0.010" [0.254]	$1\Omega < 3\Omega$	3Ω -300kΩ [500kΩ]	250mW	1W	2W
0805	3								
1005	6	0.100" [2.54]	0.050" [1.270]	0.010" [0.254]		1Ω - 3.5ΜΩ [5ΜΩ]	500mW	2W	4W
1206	5								
1505	9	0.153" [3.886]	0.050" [1.270]	0.010" [0.254]		1Ω - 4ΜΩ [6ΜΩ]	750mW	3W	6W

 $<sup>^{\</sup>scriptscriptstyle 1}$  Power Rating at 70°C derated linearly to 0% at 150°C

# PERFORMANCE SPECIFICATIONS

PROPERTY	TEST CONDITION	REQUIRED LIMITS	MSI TYPICAL LIMITS	
SHORT TERM OVERLOAD	2.5xWVDC(6.25xRATED POWER)MIL-PRF-55342, +25°C, 5 SEC	±0.25 MAX ΔR/R	±0.10 MAX ΔR/R	
HIGH TEMP EXPOSURE	+150°C, 100HRS	±0.20 MAX ΔR/R	±0.03 MAX ΔR/R	
THERMAL SHOCK MIL-STD 202, METHOD 107		±0.25 MAX ΔR/R	±0.10 MAX ΔR/R	
MOISTURE RESISTANCE	MIL-STD 202, METHOD 106	±0.40 MAX ΔR/R	±0.10 MAX ΔR/R	
STABILITY	MIL-STD 202 METHOD 108, 2000 HRS, +70°C, RATED POWER	±0.50 MAX ΔR/R	±0.10 MAX ΔR/R	

All WATF, HWTF Series parts are produced on the same manufacturing line using the same materials and processes as parts manufactured to MIL-PRF-55342



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NORTH ATTLEBORO, MA 02760

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<sup>&</sup>lt;sup>2</sup> Thickness does not include solder